

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: James D. Ballew et al.
Serial No.: 10/825,539
Filing Date: April 15, 2004
Group Art Unit: 2191
Confirmation No.: 8244
Title: *System and Method for Cluster Management Based on HPC Architecture*

Mail Stop: Amendments

Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

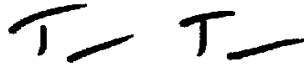
Dear Sir:

Information Disclosure Statement

Applicants submit this Information Disclosure Statement (IDS) under 37 C.F.R. § 1.97(b)(3). Applicants respectfully request the Examiner to consider and cite in the examination of this Application the documents listed in the attached Form PTO-1449. Under 37 C.F.R. § 1.98(a)(2)(ii), Applicants have provided copies of all references other than U.S. patents and U.S. patent application publications.

The Commissioner is hereby authorized to charge any fee and credit any overpayment to Deposit Account No. 02-0384 of Baker Botts L.L.P.

Respectfully submitted,
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PTO-1449 Information Disclosure Citation In an Application	Application No. 10/825,539		Applicant(s) James D. Ballew et al.	
	Docket Number 064747.1014	Group Art Unit 2191	Filing Date April 15, 2004	

U.S. PATENT DOCUMENTS

		DOCUMENT NO.	DATE	NAME	CLASS	SUBCLASS	FILING DATE
	A						
	B						
	C						
	D						

FOREIGN PATENT DOCUMENTS

		DOCUMENT NO.	DATE	COUNTRY	CLASS	SUBCLASS	TRANSLATION	
							YES	NO

NON-PATENT DOCUMENTS

		DOCUMENT (Including Author, Title, Source, and Pertinent Pages)	DATE
	E	Hans-Ulrich Heiss, "Processor Management in Two-Dimensional Grid-Architectures," Interner Bericht Nr. 20/92, XP002416087, 51 pages	Dec. 1992
	F	EPO Registered Letter, Application No. 05 252 239.8-1243, 6 pages	02.02.2007
	G		
	H		
	I		
	J		

EXAMINER	DATE CONSIDERED
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EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.

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